

Feature

- Precision MEMS process
- High performance, shielded, Micro-cavity structure
- Silicon substrate, 50Ω CPW output
- Au wire bonding, for MCM applications

Environmental Specifications

Operating Temperature	-55°C~+85°C
Storage Temperature	-55°C~+125°C
Max. Input Power	35dBm

Electrical Specifications(T_A=+25°C)

Parameter	Min.	Typ.	Max.	Unit
Center Freq. (f ₀)	-	9	-	GHz
Pass Band	8.4	-	9.6	GHz
Ripple in Pass band	-	-	1	dB
Insertion Loss @ f ₀	-	-	2.0	dB
Return Loss	12	-	-	dB
Out of band	≥30@7.6GHz&10.25GHz			dB
	≥40@7.4GHz&10.3GHz			dB
Attenuation	≥60@DC~6.5GHz			dB
	≥55@10.5~13.5GHz			dB
Group Delay Variation	≤1@8.4~9.6GHz			ns
Linear Phase	≤±10@8.4~9.6GHz			°

S2P file name: SiMF9_1R2-7D4.s2p

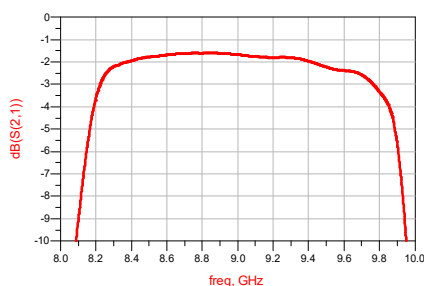
Outline Drawing



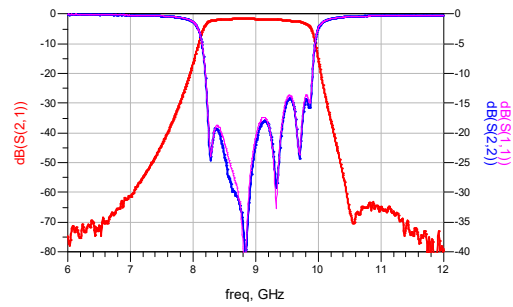
Symbol	Value (mm)		
	Min.	Nominal	Max.
A	6.9	-	7.0
B	3.8	-	3.9

Typical Test Curves

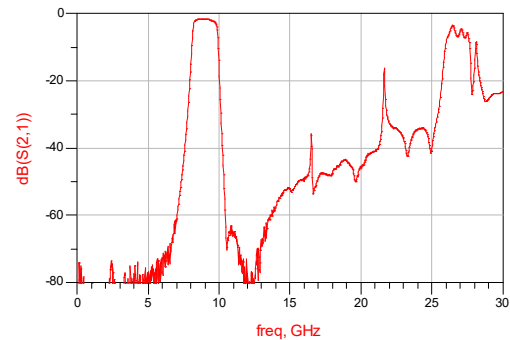
Insertion Loss VS Frequency (T_A=25°C)



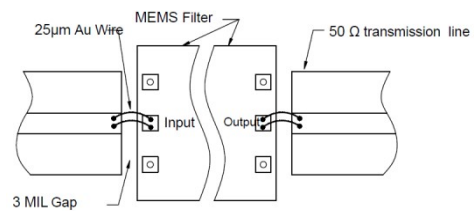
Insertion Loss & Return Loss VS Frequency (T_A=25°C)



Broadband Insertion Loss VS Frequency (T_A=25°C)



Recommended Assembly Diagrams



Application Notes:

1. The chip is back-metalized and can be die mounted with AuSn eutectic performs or with electrically conductive epoxy (for example ME8456).
2. The die should be assembled on carriers like Kovar or Mu-Cu which have same Coefficient of thermal expansion. (2.9ppm/°C) with Silicon, thickness 0.2mm max.
3. Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.
4. Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.
5. Recommended to use T structure as below for bonding.



6. If you have any questions, please contact us.